

Identifyn Standards for Optical Microscopy Methods™Identifyn® Primary Antibody**Rabbit anti-Human γ H2Ax (Serine 139) Recombinant Monoclonal, Mouse Fc, IgG (BLR014M)***Cat ID# - PA-RR 000005*Identifyn® Secondary Antibody**Identifyn® SRM Alexa Fluor™ 647 Affinity Purified Goat Anti-Rabbit, IgG (H + L)***Cat ID# - SA 000057*

Gamma H2AX (γ H2AX) is a variant of the histone H2A protein that plays a crucial role in the cellular response to DNA double-strand breaks (DSBs). Its primary function is as a marker of DNA damage, particularly in the context of DSBs. When DSBs occur in chromatin, γ H2AX is rapidly phosphorylated explicitly at the serine 139 residue (referred to as Ser139 phosphorylation or γ -phosphorylation) near the site of the break. This phosphorylation event forms γ H2AX foci, visualized via immunofluorescence microscopy techniques as an aggregate of fluorescently labeled protein at the site of breaks.

Method

HeLa cells were grown on μ -Slide 8 Well high Glass Bottom [Ibidi chamber](#), followed by -20°C methanol fixation and blocked with [Thermo Fisher Fish Serum Blocker cat#37527X3](#). The primary antibody, Rabbit anti-Human γ H2Ax Recombinant Monoclonal, Mouse Fc, IgG2a, was incubated for 1 hour at room temperature at a dilution of 1:100. Cells were washed 3X in Identifyn's™ proprietary Wash Buffer, and Identifyn® 647 secondary antibody was incubated at room temperature for 1 hour at a dilution of 1:50. Cells were washed 5X in Identifyn's™ proprietary Wash Buffer followed by the addition of Identifyn's™ proprietary STORM Buffer to the sample chamber enabling image acquisition.

Microscope

Bruker Vutara VXL Biplane Single Molecule Microscope, using an Olympus 60X/1.30 silicon oil objective, was used with the following parameters:

Calibration -

Calibration follows Identifyn's Calibration Standard Operating Procedure, which can be found here.

<https://identifyn.com/storm-calibration>

Image Acquisition -

SRX Software - Under the 'Single Molecule Localization' tab, '**Record**' is selected and contains the following workflow tabs and parameters.

Configuration Tab - Capture Configuration

Number of Probes: 1

Number of Simultaneous Probes: 1

Number of Reference Probes: 1

Camera: Both Cameras

Color Channel: Both Channels

Probe Capture Mode: Interleaved

Z-Stack Capture Mode: Interleaved

Multiple Location Capture: Not selected

Post Record Reference: Not Selected

Fluidics: Not Selected

Autofocus Drift Correction: On

Microscope configuration

Biplane Module: 635nm Dichroic

Objective: Silicon Selected

Stage Insert: Rectangular Selected
Course Focus Position: 8-Well Chamber Selected
Dichroic: SuperRes
PSF: (Red, Orange)
Heater: Current: 26

Camera Configuration

Recording Vertical Field of View: 100%
Widefield Camera Exposure Time: 100ms
Super Resolution Camera Exposure Time: 20ms
Widefield Camera Binning: 1
Per-Probe Exposure Time: Selected

Probe Configuration

Predefined Probe: First probe: 640 nm (635 nm Dichroic); First reference probe: 640 nm (635 nm Dichroic)
Photoactivation/Imaging Laser: 0% Selected
Exposure Time: 20ms Selected

Experiment Configuration

Record Workflow: Selected Options
View Mode: Widefield 200µm
Capture Mode: Live

Stage and Piezo Selection**Examination of the Sample**

Cell(s) or Cellular Structure Localization - The red-bordered box identifies the area of the SuperRes view and defines a suitable cell(s) or cellular structure. The cell(s) or structures are optimally focused.

Piezo Current: 179.5 µm

Probe 1 Laser control (640 nm (635 nm Dichroic))

Widefield 640nm: 0.1X Neutral Density Filter: Selected, @0.2% Laser Input
Reference Probe 1 Laser control (640 nm (640 nm Dichroic)): Not Selected

Advanced Tools Option

Widefield camera Exposure Time: 100ms
Default values are maintained unless otherwise noted.
Widefield Laser: "Widefield 640nm" was deselected, and "calibrate" under Autofocus was selected.

Autofocus - Calibration Values

Current Position" -0.979
Current Intensity: 4.5
Calibration Value: -5070 nm/unit
Autofocus Mode: Pre-Capture

View Mode

SuperRes: 50µm is Selected

Capture Mode

Live

Stage and Piezo Selection

Cell(s) or Cellular Structure Localization - Positioning of the target Cell or Subsection of the Target Cell is optimized and optimally focused.

Piezo Record: Begin: 180; End: 181.6

Probe 1 Laser control (640 nm (635 nm Dichroic))

SuperRes 640nm: 0.1X Neutral Density Filter: Selected, @0.02% Laser Input

Reference Probe 1 Laser control (640 nm (635 nm Dichroic))

Not Selected

Advanced Tools

Widefield Camera Exposure Time: 20ms

Default values are maintained unless otherwise noted.

Record Workflow - Record Tab: Capture Parameters

Frames: Probe 1: 200

Z Positions: 8 using Steps: 0.2µm (200nm)

Cycles: 20

Time Points: 1

Pause Between Cycles: Not Selected

Automatic Photoactivation Laser Control: Not Selected

Probe 1 Laser control (640 nm (640 nm Dichroic)

Laser Power: 50%

Expert Configuration Options - The Localization Tab

Beyond the values shown, all other parameters were set to default values.

Localization

Cutout Width: 16px

Max Frame Accumulation: 1 frame

Max Accumulation Offset: 1px

Fiducial at Max Accumulation: Not selected

Max Particles Per Frame: No Max

Background SLPE Removal: Not Selected

Cutout/Background Removal: Not Selected

Preview Cutout Positions: Selected

Record Workflow - Localization Tab**Data Collection**

The folder is created automatically with the localization file for this image acquisition.

Recording Summary

All parameters were carried over from previous tabs and are kept except:

Probe1: BG threshold: 15

Region of Interest -

Not selected

Display

Was deployed to inspect if the BG threshold applied chooses localizations in an expected manner

Record Workflow - View Tab**Region of Interest**

Default values

Visualization Parameters

Point Splatting

Sizing Mode: Radial Precision

Particle size: 4nm

Color by: Depth

Color Table: Single

Opacity Mode: Constant; Opacity 1: 08

Front-to-back Attenuation: Not Selected

Post Acquisition analysis - View Tab**Drift Correction** - Computed with the following parameters:

Method: Particle (direct)

Time Intervals: 10 Intervals

Pixel Size: 50nm

Smoothing: 8.00

Advanced Particle Filters - Applied to the drift-corrected data with the following parameters

PSF Z offset: -500 to +500

Radial precision: 25

Axial precision: 60

The other parameters were not applied.

Statistical analysis - Computed to clean low background signals.

Statistics Dialog - Cluster Analysis

Clustering Algorithm: DBSCAN

Parameters

Maximum Particle Distance: 0.1 μ m (1000nm)

Maximum Particle Count to Form Cluster: 10

Computer Hulls: Not Selected

Compute Density Isosurfaces: Not Selected

Edit Settings: All Probes

Hull Alpha shape Radius: Not Selected

Compute: Selected

Following Cluster Analysis Computation, under the Results Tab, ID Unassigned:
Deselected

Image by P. Raut

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